

	Type	L #	Hits	Search Text	DBs	Time Stamp	Errors
1	BRS	L1	346077	substrate	USPAT	2001/06/25 10:02	0
2	BRS	L2	107	porous ADJ semiconductor	USPAT	2001/06/25 10:02	0
3	BRS	L3	1108	porous ADJ silicon	USPAT	2001/06/25 10:02	0
4	BRS	L4	190	porous ADJ Si	USPAT	2001/06/25 10:03	0
5	BRS	L5	1199	2 OR 3 OR 4	USPAT	2001/06/25 10:03	0
6	BRS	L6	121	first ADJ porous ADJ layer	USPAT	2001/06/25 10:04	0
7	BRS	L7	147	second ADJ porous ADJ layer	USPAT	2001/06/25 10:05	0
8	BRS	L8	85	first ADJ porosity	USPAT	2001/06/25 10:06	0
9	BRS	L9	75	second ADJ porosity	USPAT	2001/06/25 10:07	0
10	BRS	L10	279	6 OR 7 OR 8 OR 9	USPAT	2001/06/25 10:08	0
11	BRS	L11	1253	semiconductor ADJ thin ADJ film	USPAT	2001/06/25 10:08	0
12	BRS	L12	1703	thin ADJ film ADJ semiconductor	USPAT	2001/06/25 10:09	0
13	BRS	L13	2607	11 OR 12	USPAT	2001/06/25 10:10	0
14	BRS	L14	449	1 SAME 5	USPAT	2001/06/25 10:11	0
15	BRS	L15	2	10 SAME 14	USPAT	2001/06/25 10:12	0
16	BRS	L16	0	13 SAME 15	USPAT	2001/06/25 10:12	0

looked at

09/616,395

	Document ID	Issue Date	Pages	Title
1	US 6222974 B1	20010424	14	Optical waveguide and manufacturing method thereof
2	US 6221738 B1	20010424	22	Substrate and production method thereof

	Inventor
1	Nagata, Seiichi
2	Sakaguchi, Kiyofumi , et al.